


DELEGATE BIOGRAPHY

Italy - Delegate Biography

First Name	Massimo	
Last Name	Gentili	
Title/Position	FBK-CMM DIRECTOR	
Affiliation	Fondazione Bruno Kessler - CMM	
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Massimo Gentili graduated in Solid State Physics (Laurea) at the University of Rome in 1984 and started his professional activity at CNR - Italian National Research Council in 1985, pioneering the development of Micro and Nano Scale Manufacturing technologies in Italy.

In the mid-90s he started Gate Microtechnology S.r.L, a start-up company for the development and commercialization of miniature lenses for the focusing of soft and hard x-ray radiation, which had been the object of part of his previous research. In 1999 Dr. Gentili left the CNR and moved to industry joining STMicroelectronics, Milan - Italy to lead the Advanced Lithography Group. He was then appointed STMicroelectronics Corporate Representative Officer within the International Sematech and the International Technology Roadmap for Semiconductor organizations. In 2000 he left STMicroelectronics and joined the Pirelli Group to lead the new initiative related to the "Nanoscale Development and Manufacturing Optical Technology Facility". From 2008 to 2009 Dr. Gentili was the Director of the Silicon Wafer Fabrication Facility at PGT-Photonics, the newco established by Pirelli and the USA company Cyoptics. Since March 2012 is the Director of the Centre for Materials and Microsystems of the Bruno Kessler Foundation in Trento.